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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Michael Turner; Waikit Fung; Oliver Graudejus; Doug Winandy  
Assignee: Novellus Systems, Inc.  
Title: Phosphorus-Doped Silicon Dioxide Process To Customize Contact Etch Profiles  
Serial No.: 09/998,993 Filing Date: November 15, 2001  
Examiner: Unassigned Group Art Unit: Unassigned  
Docket No.: M-12396 US

Newport Beach, California  
April 9, 2002

BOX MISSING PARTS  
COMMISSIONER FOR PATENTS  
Washington, D. C. 20231

PETITION FOR EXTENSION OF TIME

Dear Sir:

Applicants respectfully petition for a 2-month extension of time within which to respond to the December 20, 2001 outstanding Office Action, such extension allowing the undersigned until April 20, 2002 to respond.

Please charge the amount of \$400.00 as set forth in the enclosed transmittal letter.

Express Mail Label No.:

EV 004 867 153 US

Respectfully submitted,

Tom Chen  
Attorney for Applicant(s)  
Reg. No. 42,406

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400.00

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